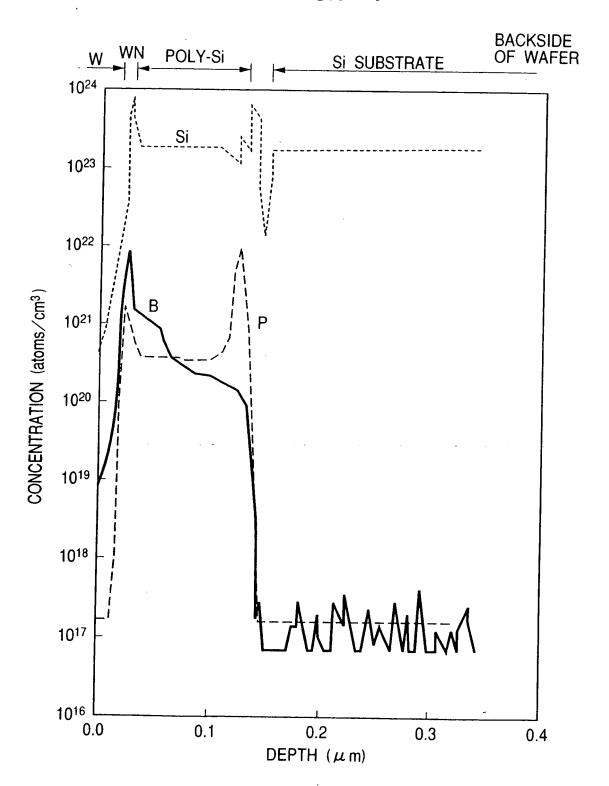
FIG. 1





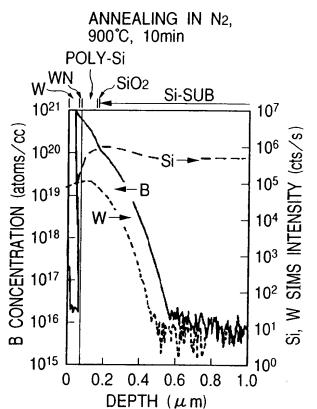


FIG. 2B

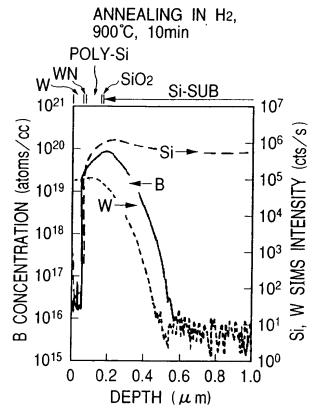
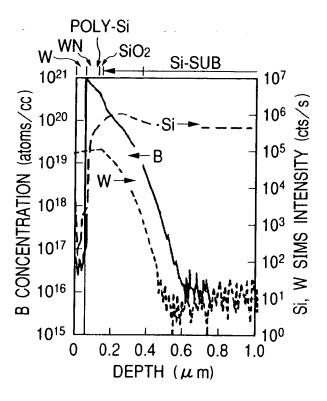
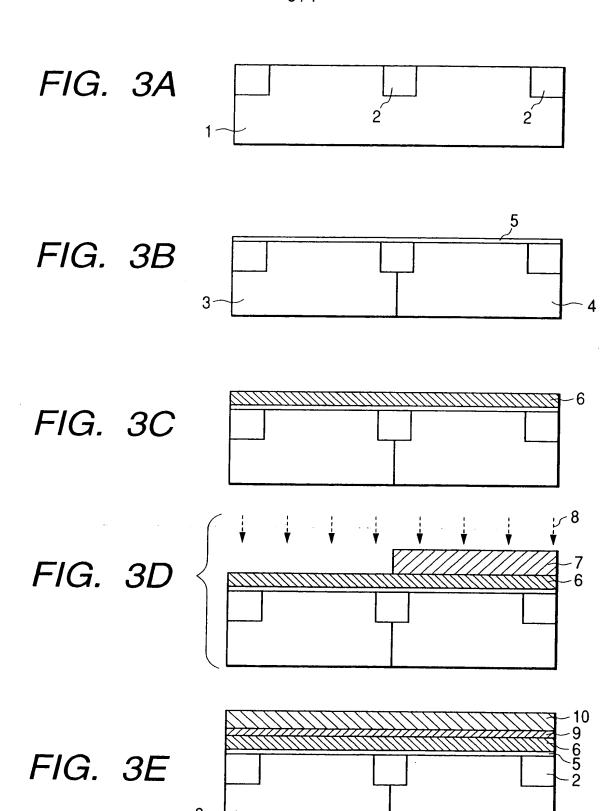


FIG. 2C

ANNEALING IN H2
WITH 5%H2O,
900°C, 10min





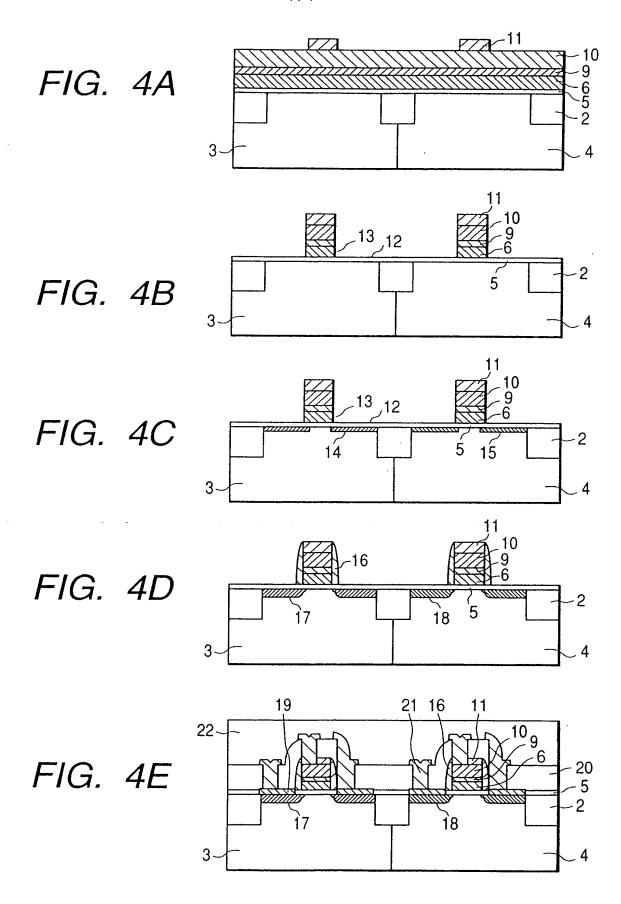


FIG. 5

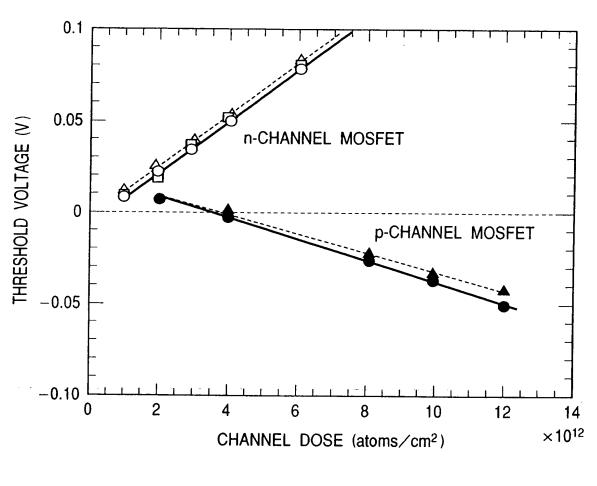


FIG. 6A

RELATIONSHIP BETWEEN DEPLETION WIDTH AND APPLIED VOLTAGE/CONCENTRATION OF SUBSTRATE

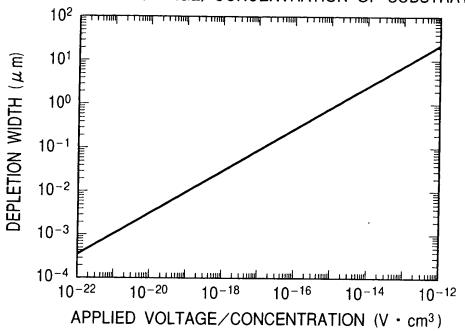


FIG. 6B

RELATIONSHIP BETWEEN BREAKDOWN VOLTAGE OF pn JUNCTION AND CONCENTRATION OF SUBSTRATE

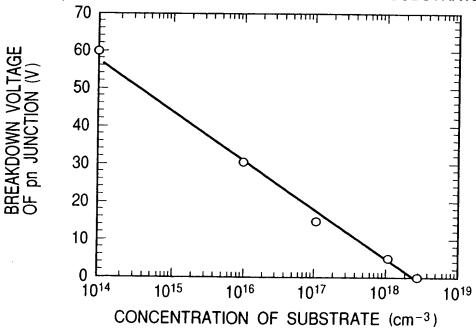


FIG. 7

